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Degradation Chemistry and Kinetic Stabilization of Magnetic Crl₃

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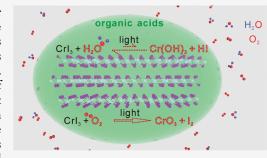
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ABSTRACT: The discovery of the intrinsic magnetic order in single-layer chromium trihalides (CrX_3 , X = I, Br, and CI) has drawn intensive interest due to their potential application in spintronic devices. However, the notorious environmental instability of this class of materials under ambient conditions renders their device fabrication and practical application extremely challenging. Here, we performed a systematic investigation of the degradation chemistry of chromium iodide (CrI_3), the most studied among CrX_3 families, via a joint spectroscopic and microscopic analysis of the structural and composition evolution of bulk and exfoliated nanoflakes in different environments. Unlike other air-sensitive 2D materials, CrI_3 undergoes a pseudo-first-order hydrolysis in the presence of pure water toward the formation of amorphous $Cr(OH)_3$ and



hydrogen iodide (HI) with a rate constant of $k_{\rm I} = 0.63~{\rm day}^{-1}$ without light. In contrast, a faster pseudo-first-order surface oxidation of CrI₃ occurs in a pure O₂ environment, generating CrO₃ and I₂ with a large rate constant of $k_{\rm Cr} = 4.2~{\rm day}^{-1}$. Both hydrolysis and surface oxidation of CrI₃ can be accelerated *via* light irradiation, resulting in its ultrafast degradation in air. The new chemical insights obtained allow for the design of an effective stabilization strategy for CrI₃ with preserved optical and magnetic properties. The use of organic acid solvents (*e.g.*, formic acid) as reversible capping agents ensures that CrI₃ nanoflakes remain stable beyond 1 month due to the effective suppression of both hydrolysis and oxidation of CrI₃.

■ INTRODUCTION

The emergent two-dimensional (2D) van der Waals (vdW) magnets not only offer an exciting platform for exploring novel spin physics in a 2D limit^{1–5} but also show great promise for spintronic applications.^{6–8} The ability to integrate them into layered heterostructures *via* vdW technology further opens up unprecedented opportunities to engineer artificial magnetic quantum materials with tailored properties for quantum technologies.⁹

Among the recently emerged vdW magnetic materials, 1,2 CrI $_3$ has been one of the most widely studied magnetic insulators in the atomically thin limit owing to its long-range ferromagnetic order and tunable interlayer magnetic coupling. 8,10 Monolayer CrI $_3$ has an out-of-plane magnetic easy axis with a Curie temperature ($T_{\rm C}$) of 45 K, 11 while few-layer CrI $_3$ favors interlayer antiferromagnetic coupling, with a $T_{\rm C}$ close to that of the bulk (61 K). Such a layer-dependent magnetic ordering can be further tuned by an external electric field, crucial for future on-chip device integration. 3,12

However, the rapid degradation of CrI₃ thin flakes under ambient conditions represents a major obstacle in both fundamental research and future practical applications. ^{1,13} The degradation rate of atomically thin CrI₃ flakes in air is much faster (within minutes) than that of other air-sensitive

2D materials [e.g., black phosphorus (BP), 14-17 NbSe₂, 18 InSe, 19-22 CrGeTe₃, etc.]. 23-27 A deep understanding of the degradation chemistry of CrI₃ is crucial for the development of an efficient stabilization strategy. 28-34 Despite extensive efforts devoted toward this goal, insights into the degradation chemistry still remain elusive. 13,35-37 The current CrI₃ stabilization strategies mainly rely on the implementation of a multistep physical encapsulation method including protection via a polymer, a hexagonal boron nitride (hBN) layer, and atomic layer deposition of metallic oxide (e.g., Al₂O₃). 13,17-22,27,37 Physical encapsulation may offer the advantage of direct device integration but lacks high scalability, solution processability, and the possibility of additional chemical functionalization, which can be achieved by using a chemical stabilization method. The latter strategy has already been exploited to stabilize air-sensitive 2D materials. 34,40-45

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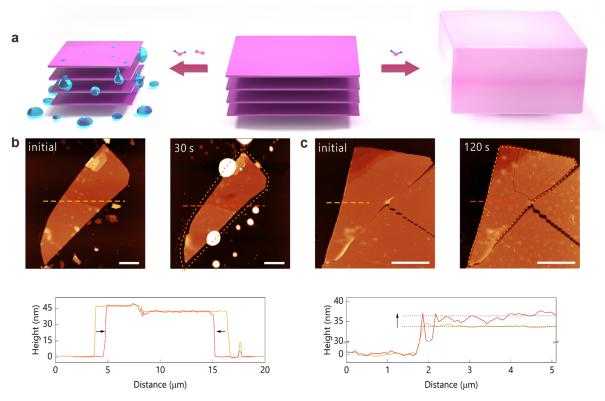


Figure 1. Degradation behaviors of CrI_3 nanoflakes in air and H_2O . (a) Schematic illustration of the degradation behaviors of CrI_3 in air and in H_2O , and corresponding AFM images and height profiles of the same CrI_3 nanoflake before and after exposure in air for 30 s (b) and before and after immersion in degassed water for 120 s (c). Note: The orange and red curves in the figure below correspond to the height changes across the dotted lines in the upper left and upper right AFM images, respectively. Scale bar: 5 μ m.

Therefore, the development of flexible chemical stabilization methods for 2D magnets is highly valuable.^{38–40}

Here, we present a comprehensive study to explain the degradation chemistry of atomically thin CrI₃ nanoflakes under different conditions. The new insights obtained inspire us to devise an efficient route for the stabilization of this material. Our studies reveal that CrI3 undergoes a photo-accelerated and pseudo-first-order hydrolysis reaction in the presence of pure water toward the formation of amorphous Cr(OH)3 and HI with a rate constant of 0.71 day⁻¹ (0.63 day⁻¹) with (without) light irradiation. Similarly, the photo-accelerated and pseudofirst-order oxidation reaction of CrI₃ readily proceeds in an O₂ environment to generate CrO3 and I2 with a larger rate constant of 4.2 $\overset{\circ}{\text{day}}^{-1}$ without light irradiation. The hydrolysis and oxidation reactions result in the ultrafast degradation of CrI₃ under an ambient environment. The new insights obtained here guided us to devise a new strategy to stabilize CrI₃ nanoflakes by using organic acids as protection solvents. It is found that CrI3 nanoflakes remain stable beyond 1 month in formic acid due to the suppression of hydrolysis and surface oxidation. Our work not only provides a new understanding of the degradation chemistry of CrI3 but also demonstrates an efficient chemical stabilization route for CrI₃, which can also be useful for the protection of a wide range of reactive 2D magnetic materials.

■ RESULTS AND DISCUSSION

We first prepared atomically thin CrI₃ flakes *via* the mechanical exfoliation of bulk crystals (Figure S1) in a glovebox filled with argon (Ar) gas. Upon exposure to air, rapid degradation of CrI₃ nanoflakes occurs, as evidenced in the appearance of

bump features within several seconds (Figures 1a,b and S2a), consistent with previous reports. ¹³ The bumps tend to develop on the edge of the nanoflake and gradually grow in size toward the flake center (Figures 1b and S2a). We also noted that dense, smaller bumps develop on the basal plane, though their size expansion is not as rapid as that of those initiated from the edge, indicating a higher chemical activity on the edge of nanoflakes. After a few minutes, only large droplets remain in place of the original nanoflakes (Figure S2a), indicating complete degradation. In addition, similar to BP³³ and InSe, ⁴⁶ degradation of CrI₃ slows down significantly with the decrease of the light intensity (Figure S3).

The rapid degradation of CrI_3 in air may arise from complex chemical reactions involving H_2O , O_2 and light. To explain the role of individual factors, we first designed the experiment to create a single-composition environment for the mechanistic study of the degradation of CrI_3 . We began with the investigation of the degradation chemistry of CrI_3 that involves either H_2O or O_2 with or without light irradiation.

Degradation Chemistry of CrI₃ in H₂O. First, we investigated the possible reaction between CrI₃ and pure H₂O. Note that a pure H₂O environment is created through Ar blowing to eliminate the dissolved gas molecules (e.g., O₂). Atomic force microscopy (AFM) was employed to monitor the change of CrI₃ nanoflakes immersed in degassed H₂O (Figure 1a,c). Distinct from the degradation behavior in air, the thickness of the whole nanoflake increases by \sim 4 nm (from \sim 33 to \sim 37 nm) after its immersion in water for 120 s. This suggests the formation of insoluble products in the reaction between CrI₃ and H₂O, leading to an increase of the film thickness (Figure S4).

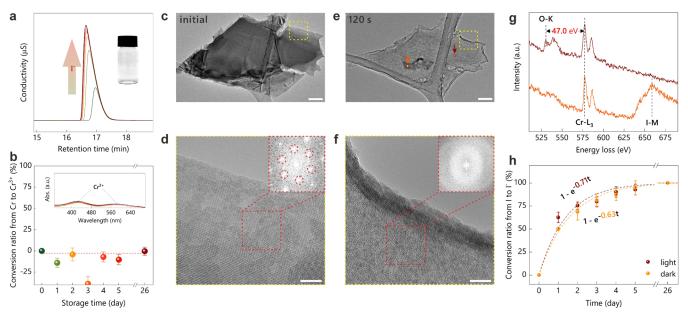


Figure 2. Probing the degradation chemistry of CrI_3 in H_2O . (a) AEC of aqueous solution as a function of time. Inset shows the supernatant solution of the sample at 5 days for AEC. (b) Relative concentration ratio between elemental Cr in CrI_3 and the Cr^{3+} ion after soaking bulk CrI_3 flakes in H_2O as a function of time, with the corresponding UV—vis spectra obtained from the aqueous solution (inset). Error bars are derived from the standard variation in UV—vis measurements of three sets of parallel experiments. TEM image (c), high-resolution TEM image (d), and corresponding FFT pattern [inset in (d)] of a fresh CrI_3 nanoflake. TEM image (e), high-resolution TEM image (f), and corresponding FFT pattern [inset in (f)] of the same CrI_3 nanoflake after a 2 minute reaction in degassed water. (g) EELS spectra were acquired at different surface regions of the CrI_3 nanoflake after soaking in H_2O for 2 min [marked in (e)]. (h) Plot of the conversion ratio of the iodine anion as a function of time (in days) under different storage conditions (light or dark, Ar). The dotted lines are the corresponding data fitting curves, and the fitting equation was labeled. Error bars are derived from the standard variation from three sets of AEC measurements of parallel samples. Scale bar: 100 nm in (c,e) and 10 nm in (d,f).

To further reveal how CrI₃ reacts with H₂O₂ anion exchange chromatography (AEC) and UV-vis spectroscopy were used to track the variation of the anion and cation in water, respectively,⁴⁷ while Fourier transform infrared spectroscopy (FT-IR), transmission electron microscopy (TEM), and electron energy loss spectroscopy (EELS) were employed to analyze the component of insoluble products (Figure S5). AEC results reveal a prominent peak at a retention time of \sim 17.0 min attributed to I⁻ (Figures 2a and S6), in contrast to the rather featureless spectra obtained from blank water (Figure S6a). The peak intensity increases as a function of storage time, indicating the generation of I⁻ from the reaction of CrI₃ with H₂O. In addition, UV-vis spectroscopy reveals a negligible change of the adsorption feature associated with chromium cations (Cr3+), suggesting that no additional chromium cation was generated by the sample degradation (Figures 2b and S7). Therefore, a combination of AEC and UV-vis spectroscopic studies reveals that CrI₃ undergoes hydrolysis in H₂O, which mainly yields I⁻ anions. This is also further supported by a gradual decrease of the pH value of the solution from ~6 to ~4, attributed to the formation of HI from the hydrolysis of CrI₃.

In addition to the analysis of the soluble components, the insoluble products of the reaction with H_2O were also identified. XPS and FT-IR spectra acquired indicate that an insoluble product is likely to be chromic hydroxide (Figures S8, S9), as evidenced by the observation of the features of $Cr(OH)_3$ in $Cr\ 2p$ and O 1s spectra, a bending mode of Cr-O at $\sim 545\ cm^{-1}$ and a bending mode of O-H at $\sim 1619\ cm^{-1}$ in the FT-IR spectra. $^{48-50}$ In addition, we also employed TEM and EELS (Figure 2c-g) to further probe the crystallinity and composition of the materials before and after the reaction with

H₂O. Prior to the reaction with H₂O, a fresh CrI₃ nanoflake with a lateral dimension of ~800 nm (Figure 2c) shows a high crystalline state with a hexagonal lattice (Figure 2d) and a characteristic diffraction pattern, as revealed in the corresponding fast Fourier transform (FFT) analysis varied the monocrystalline CrI_3 (C2/m). After 2 min of soaking in H₂O (Figure 2e), an obvious change of the TEM contrast was observed in a large portion of the CrI3 nanoflake, which indicates a significant degradation. Note that only a small area of the CrI₃ nanoflake survived. The disappearance of the CrI₃ lattice in degraded regions, in combination with the resulting indistinct FFT pattern (Figure 2f), reflects a crystalline-toamorphous transition as the reaction proceeds. In a subsequent EELS analysis, it was noted that the differences between the Cr L-edge features of the EELS spectra acquired in the degraded sample regions (deep red curve in Figure 2g) and in the surviving sample regions (orange curve in Figure 2g) were negligible. However, a new feature located at 530.5 eV is observed in the degraded region and is attributed to the O Kedge, which suggests that the insoluble product derived from hydrolysis is likely to be amorphous chromium (III) hydroxide.⁵¹ Based on these spectroscopic studies and on TEM imaging, the degradation reaction between CrI₃ and H₂O can be described using the following chemical equation

$$CrI_3 + 3H_2O \rightarrow Cr(OH)_3 + 3HI$$

The degradation kinetics of bulk CrI₃ flakes in H₂O was further studied by tracking the time-dependent quantitative variation of the I⁻ concentration with and without light irradiation. Figure 2h reveals a monoexpotential increase of the relative conversion ratio of elemental I in CrI₃ into I⁻ as a function of time, suggesting a pseudo-first-order reaction

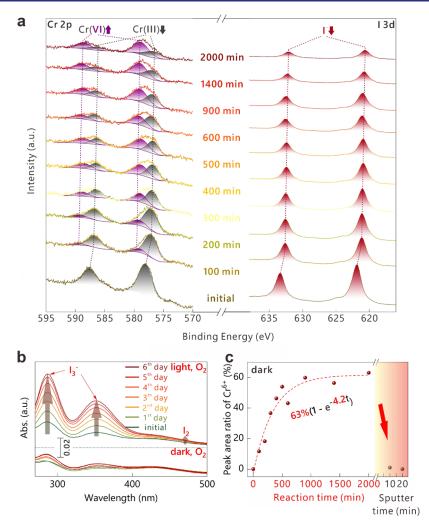


Figure 3. Probing the degradation chemistry of CrI_3 in O_2 . (a) In situ XPS Cr 2p and I 3d spectra of bulk CrI_3 in a pure oxygen atmosphere within 2000 min of the start of the degradation. (b) UV—vis spectra of aqueous solutions containing bulk CrI_3 and dissolved oxygen under light (up) and dark (down) as a function of time. (c) Increase and decrease of the peak area ratio of hexavalent chromium $[A_{Cr(VI)}/(A_{Cr(VI)}+A_{Cr(III)})]$ with time. The dashed line is the corresponding data fitting curve for oxidation within 2000 min, and the fitting equation is labeled. The oxidized surface can be removed *via* Ar sputtering (orange region).

between CrI_3 and $H_2O.^{47}$ Here, the concentration of H_2O and $Cr(OH)_3$ (low K_{sp} : 6.3 \times 10⁻³¹) can be assumed to be constant. Therefore, the hydrolysis rate of CrI_3 , r, can be written as

$$r = -\frac{\mathrm{d}[\mathrm{CrI}_3]}{\mathrm{d}[t]} = \frac{\mathrm{d}[\mathrm{I}^-]}{3 \, \mathrm{d}[t]}$$

The concentrations of produced $I^-([I^-])$ as a function of reaction time (t), can be deduced from the equation

$$[I^{-}] = 3[CrI_3]_0(1 - e^{-k_I t})$$

where $[CrI_3]_0$ is the concentration of CrI_3 at t = 0 and k_I is the rate constant of the generation of I^- . Monoexponential fitting yields reaction rate constants (k_I) of 0.71 and 0.63 day⁻¹ with and without light, respectively. This also points out that light irradiation accelerates the hydrolysis.

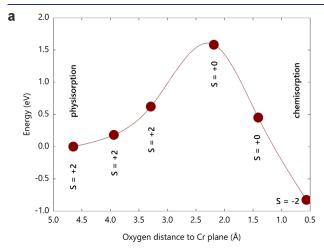
Degradation Chemistry of Crl₃ in an O₂ Environment. Next, we probe the reaction between CrI₃ and O₂ using *in situ* X-ray photoelectron spectroscopy (XPS). Both the bulk and nanoflakes may undergo similar surface oxidation. However, bulk CrI₃ samples can be readily cleaved under ultra-high vacuum conditions to obtain fresh surfaces for *in situ* XPS. We collected a series of XPS spectra to track the composition change of the bulk CrI3 flake stored in a pure O2 atmosphere at close to atmospheric pressure (Figure 3a). The features at 578.1 and 587.6 eV associated with Cr 2p become gradually broadened, while peaks centered at 621.8 and 633.3 eV attributed to I 3d are gradually weakened as a function of time (the area of the peak centered at 621.8 eV drops by \sim 72% after 2000 min). In addition, a new set of peaks appear at 579.1 and 589.3 eV, higher than that of Cr 2p of intrinsic CrI₃. These new peaks can be assigned to Cr(VI),52 indicating the oxidation of CrI3 in a pure O2 environment. A decrease in the peak intensity related to I 3d indicates the desorption of the I element. A gradual red shift in peak position as a function of time is likely due to an increased surface charging effect as the oxidation proceeds. In addition, we also observed that elemental iodine (I2) can be generated in water containing dissolved O₂ and CrI₃ (Figure 3b), indicating that CrI₃ reacts with O2 to form I2. Moreover, the formation rate of I2 from oxidation can be further accelerated by exposure to light (Figure 3b). All these observations suggest that the reaction of CrI₃ with O₂ leads to the formation of I₂ and CrO₃, which can be described by the following equation

$$2CrI_3 + 3O_2 \rightarrow 2CrO_3 + 3I_2$$

Similar to the hydrolysis reaction between CrI_3 and H_2O_7 , the kinetics study for the reaction with O_2 also reveals a monoexponential increase in the peak area ratio of Cr(VI) as a function of time (Figure 3c), suggesting a pseudo-first-order reaction. The corresponding rate constant k_{Cr} for the reaction in dark under a pure O_2 atmosphere (\sim 2 bar) was determined to be 4.2 day⁻¹, through a monoexponential fitting of the experimental data. Such a value is nearly an order of magnitude higher than that of the hydrolysis reaction, suggesting a much faster oxidation reaction.

In addition, the oxidation ceases at a later stage [a maximum of \sim 63 mol % Cr was oxidized into Cr(VI)], as shown in Figure 3c, suggesting a self-limiting oxidation process. That is to say, the surface of CrI $_3$ was oxidized into Cr(VI), and the remaining CrI $_3$ layers buried underneath can survive due to the protection from the surface oxide layer. This is also taking into account the surface sensitivity of the XPS technique, which only acquires photoemission electrons within a depth of several nanometers from the top surface. Moreover, the peak area ratio of Cr(VI) drops to nearly zero after Ar sputtering (orange region in Figure 3c) on the surface of bulk CrI $_3$.

We have used density functional theory (DFT) calculations ⁵³ to confirm the feasibility of these reactions. The binding energy for a physiosorbed oxygen molecule is 0.18 eV. The calculated energetic profile (Figures 4a, S10, and Table S1) reveals that the subsequent reaction between O₂ and CrI₃ requires overcoming a moderate energy barrier of 1.6 eV, which is anticipated to be further lowered due to the presence of atomic defects in the materials (Figure S11). Nevertheless, the whole reaction is energetically favorable with an energy



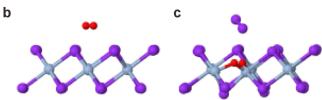


Figure 4. DFT calculations of oxygen adsorption with release of I_2 . (a) Energy profile for the reaction between physisorbed O_2 and CrI_3 , resulting in a chemisorbed oxygen dimer and with release of I_2 , along with the respective structures for the physisorbed state (b) and chemisorbed state (c). S indicates the spin state of the structure relative to the original spin state of CrI_3 , in units of the electron spin.

gain of 0.89 eV. The reaction between O_2 and CrI_3 results in the oxidation of CrI_3 (O atoms are chemically bonded to Cr atoms, Figure 4b,c) and a release of I_2 , consistent with the experimental observation. We have not performed similar calculations for the reaction between CrI_3 and liquid water due to the difficulty in representing the liquid behavior and energetics, which are different from those of gaseous water. In case of gaseous H_2O , our DFT calculation reveals that hydrolysis of CrI_3 occurs through the dissociation of H_2O molecules and release of HI, wherein hydrogen and hydroxyl bind to adjacent iodine atoms and chromium atoms, respectively. In addition, H_2O also reacts with iodine vacancies, which is an endothermic process. As the reaction with water proceeds, CrI_3 can be fully converted into $Cr(OH)_3$ (Figure S12 and Table S1).

With the help of calculations, we draw a picture of possible degradation processes, and as summarized in Figure S13, the hydrolysis and oxidation of ${\rm CrI_3}$ are major chemical reactions attributed to its rapid degradation in air (Figure S14, 15), while the light is found to accelerate the whole degradation process likely due to the spin transition triggered in the case of the oxidation reaction (Figure S10) and effects of heat from illumination. New chemical insights obtained here help us develop an efficient strategy for the stabilization of ${\rm CrI_3}$ via a judicious choice of acidic solvents, which can suppress both hydrolysis and oxidation.

Stabilization of Crl₃ in Organic Acid Solvents. A trace amount of water and oxygen in the environment, which are hard to remove completely, will induce the degradation of CrI₃. Typically, the concentration of dissolved oxygen is reduced in solvents, which thus suppresses the oxidation. An oreover, an increase of the proton concentration is expected to inhibit the hydrolysis reaction of CrI₃ (Figure 5a), but this has to eliminate the aqueous acidic solution due to the presence of a large amount of H_2O . Even in a strong acidic aqueous solution (pH \sim 2), bulk CrI₃ flakes are completely degraded within 3 days (Figure S16). Therefore, our key protection idea lies in the choice of the organic acid solution (e.g., formic acid, the simplest organic acid) to suppress the chemical reactions discussed above.

First, the effective protection of CrI₃ in formic acid can be verified based on the negligible color variation of the solvents containing bulk CrI₃ in an ambient environment, in contrast to a fast color change for CrI3 flakes stored in other nonacidic solvents, such as acetone, hexane, acetonitrile, and so forth (Figures 5b and S17). The morphology of the CrI₃ nanoflake still remains intact after being kept in formic acid for 2 weeks (Figure 5c,d). Energy-dispersive X-ray spectroscopy (EDS) mapping of Cr and I elements (Figure 5e,f) combined with the observation of the characteristic E_g mode at 107 cm⁻¹ and A_{1g} mode at 129 cm⁻¹ in the Raman spectrum (Figure 5g-i) further verifies that the crystal structure of CrI3 is preserved 13,55,56 during storage in formic acid for 14 days. In addition, a similar protection effect was obtained for CrI3 kept in acetic acid (Figure S18), while CrI3 undergoes an obvious degradation in other commonly used organic solvents within the same time frame (Figure S19). It is noted that CrI₃ nanoflakes stored in formic acid for 1.5 months present negligible changes, but the nanoflakes stored in acetic acid show partial degradation (Figure S20).

To reveal the microscopic picture of formic acid stabilization, DFT calculations were used (Figure S22). It is concluded that formic acid molecules (HCOOH) tend to

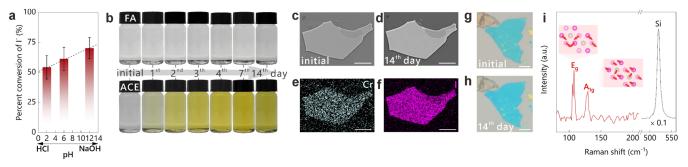


Figure 5. Stabilizing CrI_3 in organic acid. (a) Percentage of the conversion of CrI_3 into I^- for bulk CrI_3 flakes immersed in water with different pH values after the degradation reaction ceases (no degassing). The percentage of conversion decreases with the decrease of pH, indicating that the acid inhibits the hydrolysis of CrI_3 . (b) Optical photographs of bulk CrI_3 flakes stored in different organic solvents under an ambient environment. FA: formic acid and ACE: acetone. SEM images of the same CrI_3 nanoflake soaking in FA at the initial state (c) and after 14 days (d) and EDS mapping of the Cr and I elements (e,f) of the flake after 14 days. Optical microscopy images of the same CrI_3 nanoflake soaking in FA under ambient conditions at the initial state (g) and after 14 days (h). (i) Raman spectra of the CrI_3 nanoflake in (g): E_g mode (up) and A_{1g} mode (down). Note: The silicon reference signal was reduced by a factor of 10. Scale bar: 10 μ m.

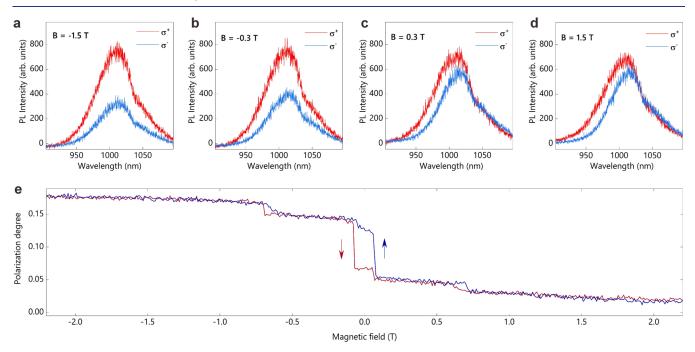


Figure 6. (a–d) The low-temperature (1.6 K) PL spectra under microscopic 532 nm excitation of an exfoliated CrI₃ nanoflake, which was soaked in formic acid, demonstrate a broad near-infrared emission band akin to the optical response of the hBN-encapsulated CrI₃ layers. The emission observed below the Curie temperature is characterized by a finite circular polarization degree. (e) Its evolution in a magnetic field displays a hysteresis indicative of the ferromagnetic order of the magnetic moments associated with the Cr atoms.

physically adsorb on prefect CrI_3 but tend not to react destructively with it and that COOH radicals can bind to iodine vacancies. In this case, the vacancies and basal plane are passivated and will not serve as binding sites for water and oxygen dissociation, and protons are generated with the formation of COOH radicals, which further slow the hydrolysis reaction of CrI_3 .

The preservation of the exfoliated CrI₃ flakes within organic acids enables probing their electronic and magnetic properties through the inspection of open and unprotected films. In this regard, we have investigated the magneto-photoluminescence (PL) response of CrI₃ layers deposited on Si/SiO₂ substrates comparatively with those that are protected through hBN encapsulation. As demonstrated in Figure 6, the PL observed in the CrI₃ nanoflake treated with organic acids is characterized by an emission band in the near-infrared spectral region. Such an optical response is characteristic of Frenkel excitons at the

limit of strong electron-phonon coupling.⁵⁷ The intensity of the PL signal resolved by circular polarization and monitored as a function of the magnetic field reveals hysteresis. This observation signifies a coupling between the angular momentum of the photoexcited carriers and the magnetic moments of Cr atoms. In the presence of such a coupling, the population of the excitons is redistributed between spin-split excitonic levels, which are active in polarizations. Hence, monitoring the polarization degree of the PL grants insights into the evolution of magnetization state of CrI₃. The dominant contribution to the hysteresis centered around 0 T is indicative of the emergent global ferromagnetism for fewlayer CrI_3 , while the multiple steps observed from -1 T to 1 T can be attributed to partial flipping of antiferromagnetically coupled adjacent layers in combination with the domaindependent hysteresis response observable in few-layer and bulk chromium trihalide crystals. 58-60 Further examples of hysteresis loops seen in unprotected flakes of various thicknesses for CrI₃ and CrBr₃ materials are demonstrated in Figures S24 and S25. Qualitatively, we found that immersion in organic acid is a valid alternative for physical protection of the 2D magnets, enabling further progress toward investigations of their fundamental properties and their incorporation into structures of technological importance. Compared with the physical protection methods previously reported, ^{13,17–22,27,37} this wet chemical stabilization strategy offers the additional advantages of high scalability and processibility, especially under atmospheric conditions, which are of importance for the large-scale and low-cost fabrication of 2D magnet-based devices.

CONCLUSIONS

In summary, we have gained a new understanding of the degradation chemistry of a prototypical 2D magnetic material, CrI₃, in different chemical environments. Our studies uncover that CrI₃ undergoes a pseudo-first-order hydrolysis in pure water with the formation of Cr(OH)₃ and HI, while a faster pseudo-first-order surface oxidation of this material readily occurs in an O2 environment to generate CrO3 and I2. Both hydrolysis and surface oxidation of CrI3 can be accelerated with light irradiation, attributed to its ultrafast degradation in air. The insights thus obtained allow us to develop an effective protection strategy by exploiting organic acids as reversible capping agents to preserve its optical and magnetic properties. CrI3 remains stable in organic acids beyond 1 month due to the suppression of both the hydrolysis and the surface oxidation. Our findings may further boost both fundamental research and the future technological application of airsensitive magnetic quantum materials.

ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge at https://pubs.acs.org/doi/10.1021/jacs.1c08906.

Additional experimental details, materials, methods, and theoretical calculation results of the energetic profile and reaction enthalpies (PDF)

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Notes

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